

Corrections to “Highly Conductive and Broadband Transparent Zr-Doped In₂O₃ as Front Electrode for Solar Cells”

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In the paper [1], the reported values of the oxygen to total flow ratio, defined as $r(\text{O}_2)$ in %, should be multiplied by a factor of 3 ± 0.1 , which corresponds to the correct calibration factor for the mass flow controllers. This correction should be applied consistently throughout the paper where the $r(\text{O}_2)$ (%) is mentioned.

It is important to note that this correction does not change the conclusion of the article, and all the results presented remain valid.

REFERENCE

- [1] M. Morales-Masis *et al.*, “Highly conductive and broadband transparent Zr-doped In₂O₃ as front electrode for solar cells,” *IEEE J. Photovol.*, vol. 8, no. 5, pp. 1202–1207, Sep. 2018.

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